

Supporting Information

**3D silver nanoparticles with Multilayer graphene oxide as a**

**Spacer for Surface Enhanced Raman Spectroscopy Analysis**

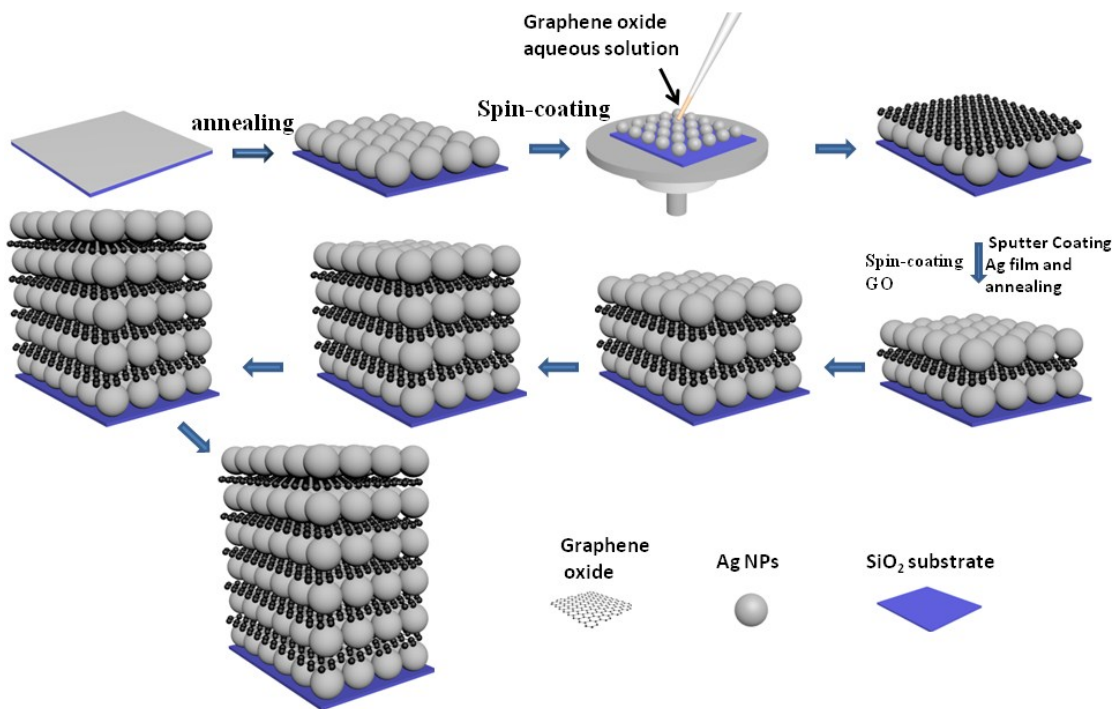
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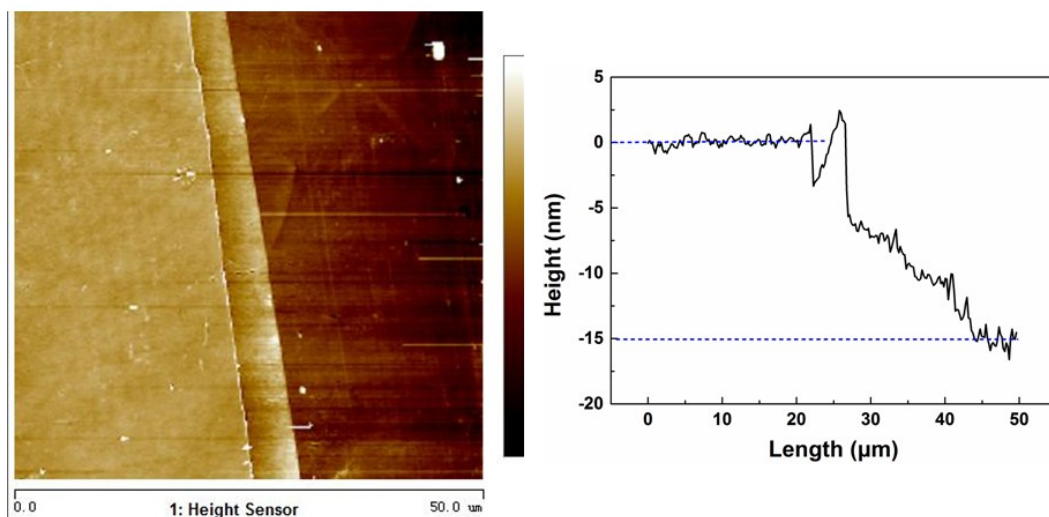
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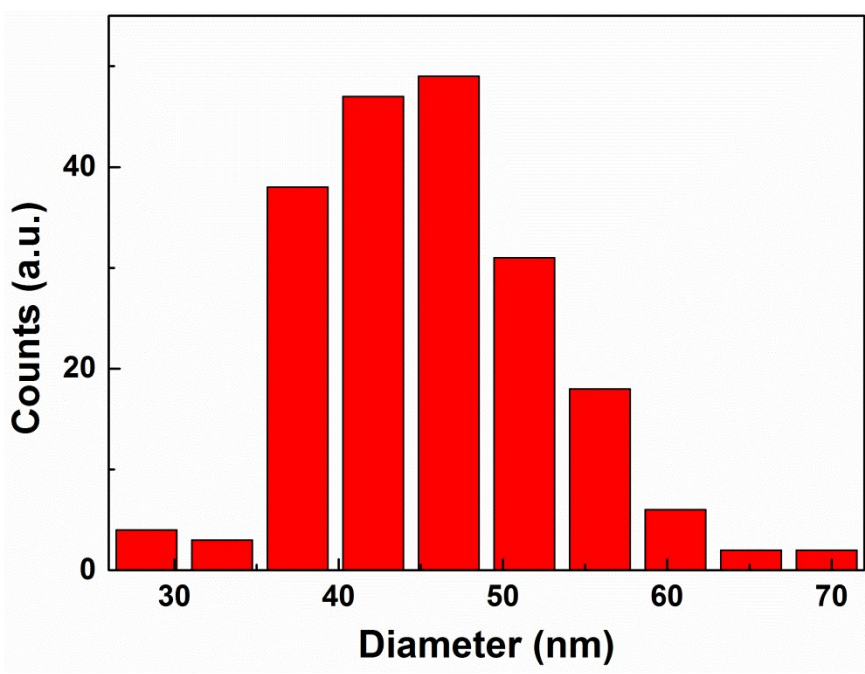
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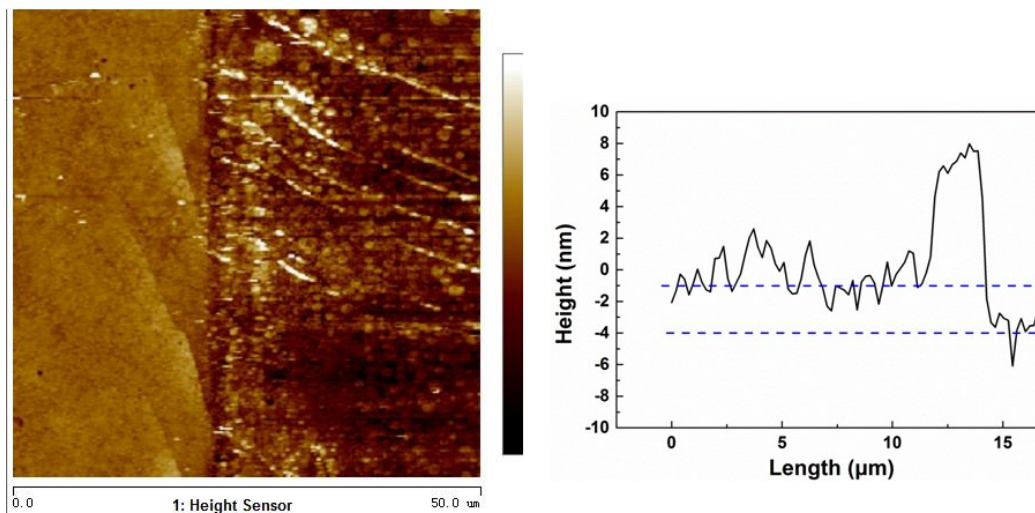
**Fig. S1** Schematic illustration of the fabrication of different layers of Ag NPs using multilayer GO as spacer.



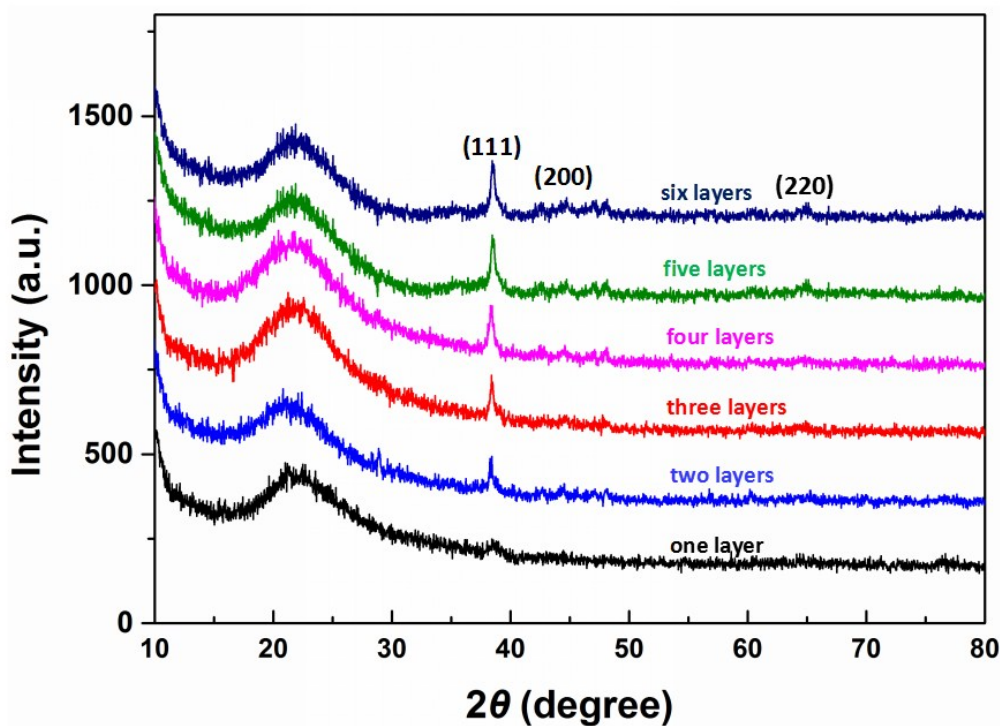
**Fig. S2** AFM image of Ag film and its corresponding height profile.



**Fig. S3** The statistical histograms of the size of Ag NPs.

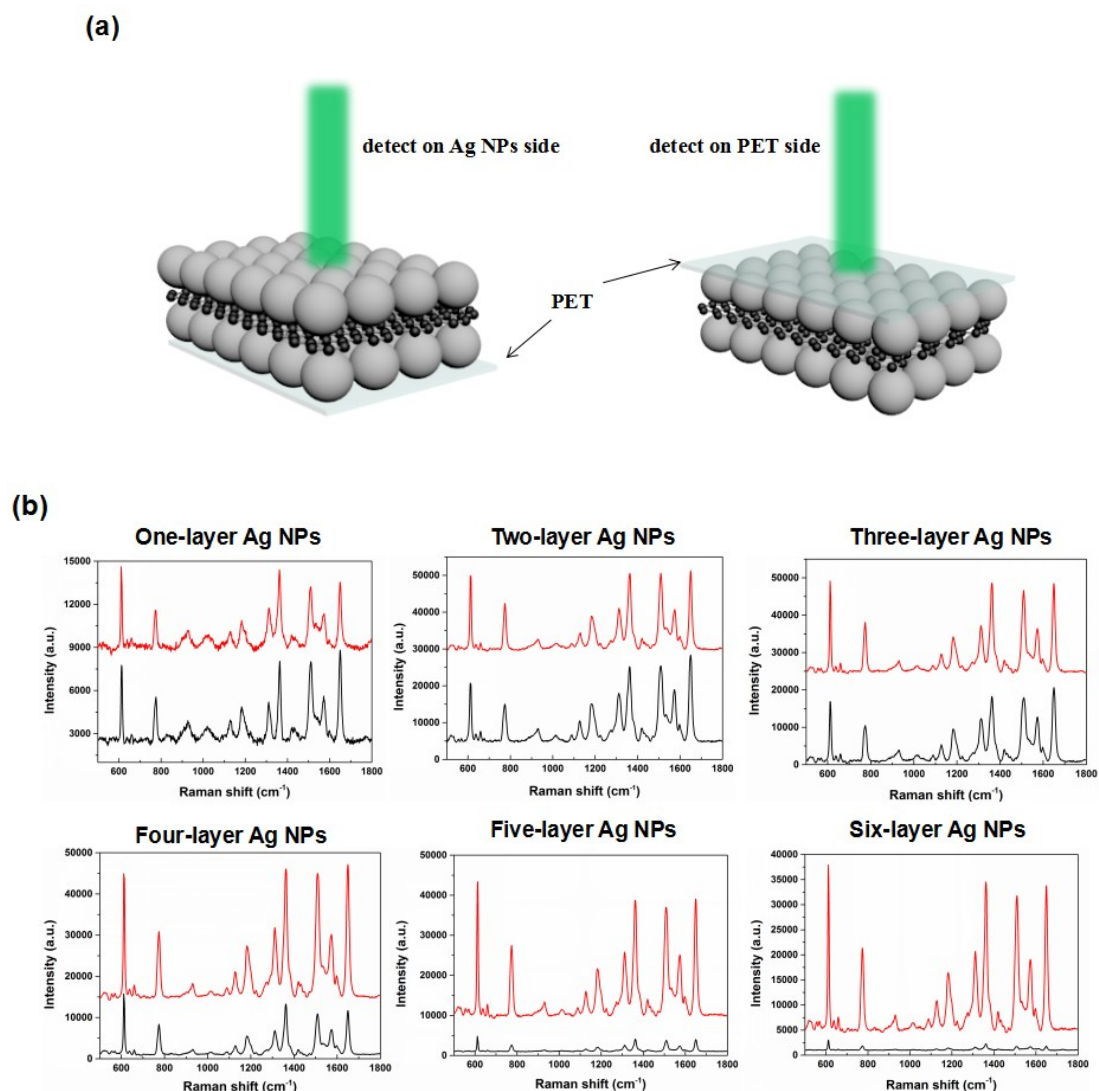


**Fig. S4** AFM image of multilayer GO and its corresponding height profile.



**Fig. S5** XRD patterns of the 3D Ag NPs nanostructures with different Ag NPs layers using GO as spacer.

Detailed explanation for the fact that very few probe molecules can penetrate into the 3D structure



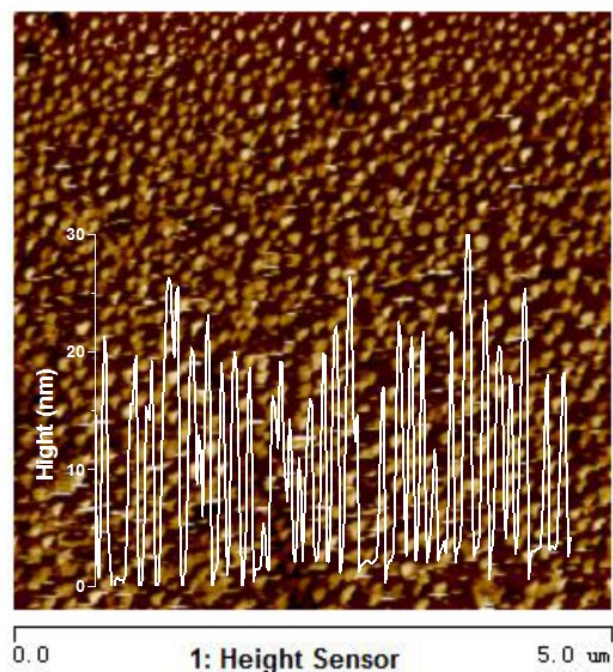
**Fig. S6** (a) Schematic illustration of the two detection way for the 3D structure. (b) SERS signal of R6G detected on PET side (black line) and on Ag NPs side (red line) was adopted for study.

To investigate whether the analytes could penetrate the GO film, we fabricate the 3D structure with different Ag NPs layers using GO as spacer on the ultra-thin polyethylene terephthalate (PET) which is a kind of stable polymer with high transparency. Fig. S6a schematically exhibits the two SERS detection way for the 3D

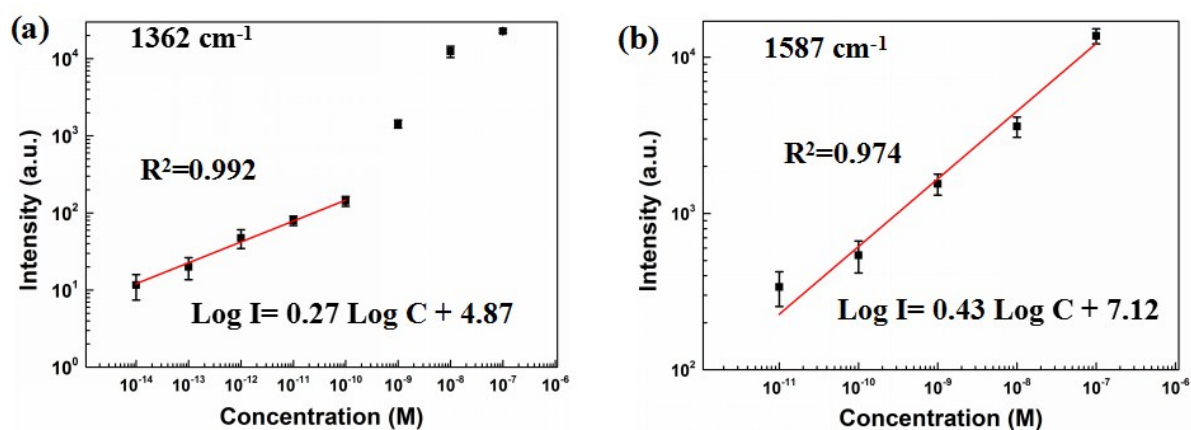
structure on PET. 2  $\mu\text{L}$  R6G ( $10^{-7}$  M) was firstly deposited on the Ag NPs side. SERS signal of R6G detected on PET side (black line) and on Ag NPs side (red line) are shown in Fig. S6b. In the one-layer and two-layer Ag NPs structure, we found that the R6G signals observed from the Ag NPs side are almost identical with that obtained from the PET side which indicates that the PET is almost no influence for the SERS detection. However, for the SERS signal obtained from the three-layer and four-layer Ag NPs structure, we note that the intensity of the R6G signal obtained from the Ag NPs side is stronger than that obtained from the PET side. The result can be explained by these factors: first, for the PET side detection, the Raman scattered signal of R6G should penetrate the three or four layers Ag NPs to be collected by the Raman detectors and there should exist inevitable optical losses. The Ag NPs side detection is more easy to obtain the Raman scattered signal of R6G. Second, few probe molecules can penetrate into the 3D structure.

The thickness of the four-layer Ag NPs in this 3D structure should be the maximum penetration depth that the incident laser can penetrate, which has been proved in main article. However, for the five-layer and six-layer Ag NPs structure, the R6G signals can be still observed on the PET side, which demonstrates that the probe molecules can indeed penetrate into the 3D structure. Besides, we can observe that the SERS signals of R6G obtained from the Ag NPs side are significantly stronger than that obtained from the PET side. It is indicated that only very few probe molecules can penetrate into the 3D structure for the obstruction of the thick GO films. Thus, the SERS performance of the 3D nanostructures can be mainly attributed to the topmost hot spots. The electromagnetic field intensity of the topmost hot spots is related closely to the number of Ag NPs layers which is investigated both in experiments and theoretical modeling in the main article.





**Fig. S7** the AFM image of the Ag NPs and its corresponding height profile.



**Fig. S8** SERS intensity at  $1362\text{ cm}^{-1}$  (a) as a function of R6G molecular concentration and  $1587\text{ cm}^{-1}$  (b) as a function of CV molecular concentration. Error bars indicate standard deviations from at least 30 spectra.

### Detailed calculative process of the enhancement factor

Rhodamine 6G (R6G) and Crystal violet (CV) were dissolved in water to obtain the solution from  $10^{-2}$  to  $10^{-15}$  M and from  $10^{-2}$  to  $10^{-12}$  M, respectively. When the concentrations of R6G are lower than  $10^{-11}$  M, we can only obtain the SERS signal of R6G from the edge of the final evaporation imprint. Thus, to guarantee the scientific nature of the results, the  $10^{-11}$  M R6G solution was chosen as the limit concentration for calculation of the enhancement factor. Similarly, the  $10^{-10}$  M CV was chosen as the limit concentration for calculation of the enhancement factor. 2  $\mu$ L R6G with the concentration  $10^{-2}$  and  $10^{-11}$  M were dropped separately on the SiO<sub>2</sub> substrate and fabricated SERS substrates. 2  $\mu$ L CV with the concentration  $10^{-2}$  and  $10^{-10}$  M were also dropped separately on the SiO<sub>2</sub> substrate and fabricated SERS substrates. Before carrying out the Raman detection, the samples were all totally dried. The estimated maximum diameter of the final evaporation imprint on SiO<sub>2</sub> substrate were around 2.5 mm for R6G ( $10^{-2}$  M) and CV ( $10^{-2}$  M). And the estimated maximum diameter of the final evaporation imprint were around 2 mm for R6G ( $10^{-11}$  M) and CV ( $10^{-10}$  M) for the hydrophobic property of the fabricated substrate. Thus, the average areal density (AD) of the R6G and CV can be estimated by the following equation:  $AD = CVN / S$ , where  $V$ ,  $C$ ,  $N$  and  $S$  represent the volume of the analytes solution dropped, the concentration of analytes solution, Avogadro constant and the area of the analytes molecules covered, respectively.

With the R6G concentration of  $10^{-11}$  M, the AD is around 3.83 molecules/ $\mu$ m<sup>2</sup>.

With the CV concentration of  $10^{-10}$  M, the AD is around 38.3 molecules/ $\mu$ m<sup>2</sup>.

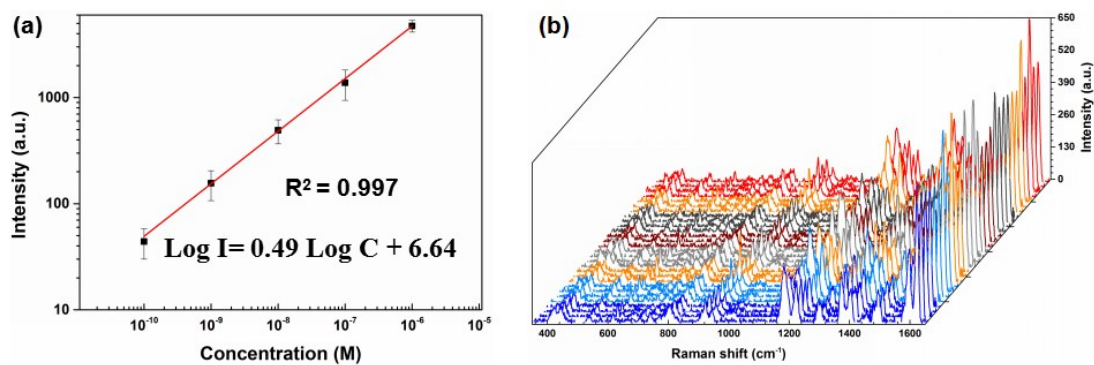
With the R6G and CV concentration of  $10^{-2}$  M, the AD on SiO<sub>2</sub> is around  $2.45 \times 10^9$  molecules/ $\mu$ m<sup>2</sup>.



The enhancement factor was estimated by the following equation:  
$$EF = (I_{SERS} \times N_{SiO_2}) / (I_{SiO_2} \times N_{SERS})$$
, where  $I_{SERS}$ ,  $I_{SiO_2}$ ,  $N_{SiO_2}$  and  $N_{SERS}$  represent the intensity of SERS signal, Raman signal intensity obtained from SiO<sub>2</sub>, the number of analytes molecules within laser spot on SiO<sub>2</sub> substrate and the number of molecules within laser spot on SERS substrate, respectively. The Raman spectrometer was all used under the condition (0.3 mW laser power, × 50 objective lens, 1 μm laser spot). The Raman signal intensity of R6G (10<sup>-11</sup> M) and CV (10<sup>-10</sup> M) obtained from 3D SERS substrate, R6G (10<sup>-2</sup> M) and CV (10<sup>-2</sup> M) collected from SiO<sub>2</sub> substrate are shown in Fig. 5c and d. Thus, the average EF of the 3D SERS substrate for R6G and CV can be obtained.

**Table 1** Comparison of our work with other 3D SERS substrates reported.

Structure	Calculation method	EF	Reference
GO/AgNPs/pyramidal silicon	$AEF = (I_{SERS} \times N_{Raman}) / (I_{Raman} \times N_{SERS})$ $10^{-3}$ M R6G solution on pyramidal silicon and $10^{-11}$ M on the structure	$1.27 \times 10^8$	37
CuNPs/graphene/Cu film	$EF = (I_{SERS} / I_{bulk}) \times (N_{bulk} / N_{SERS})$ 0.5 nm CuPc on the structure and 100 nm CuPc on the silicon substrate	$1.9 \times 10^7$	23
3D cross-point plasmonic nanostructures	$AEF = (I_{SERS} \times N_{film}) / (I_{Normal} \times N_{SERS})$ $10^{-3}$ M R6G and $10^{-11}$ M on the structure	$4.1 \times 10^7$	33
AuNPs/Multilayer Graphene/ AuNPs	$EF = (I_{SERS} / I_{REF}) \times (N_{REF} / N_{SERS})$ $10^{-2}$ M BCB on a glass substrate and $10^{-6}$ M on the structure	$2.89 \times 10^5$	25
Multiple Ag NPs	$EF = (I_{SERS} / I_{bulk}) \times (N_{bulk} / N_{SERS})$ $10^{-9}$ M R6G on the structure and solid R6G	$1.5 \times 10^7$	34
Silver nanoislands on silica spheres	$EF = (I_{platform} / I_{platform}) \times (N_{reference} / N_{reference})$ , $10^{-3}$ M R6G on the silicon wafer and $10^{-11}$ M on the structure	$3.76 \times 10^7$	38
Multilayer Ag NPs using GO as spacer	$AEF = (I_{SERS} \times N_{SiO_2}) / (I_{SiO_2} \times N_{SERS})$ $10^{-2}$ M R6G on $SiO_2$ and $10^{-11}$ on the structure	$7 \times 10^8$	Current work



**Fig. S9** (a) The calibration curve of normalized Raman intensity at  $1179 \text{ cm}^{-1}$  versus the concentration of MG. (b) 30 SERS spectra of MG ( $10^{-9} \text{ M}$ ) collected randomly from the 3D nanostructure.